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## You are cordially invited to visit **First Nano** at... the **2011 MRS Spring Exhibit**

**First Nano**, a division of **CVD Equipment Corp.**, **Booth 517**, cordially invites you to attend our exhibit at the 2011 MRS Spring Meeting in San Francisco. First Nano and CVD Equipment deliver Research and Production chemical vapor deposition solutions for Process Equipment, Gas Cabinets and Gas Abatement, as well as Applications Laboratory Services including **CVDGraphene™**, CNTs, Nanowires and Thin Film Deposition. Our **CVDGraphene™** products are sold through [Graphene Supermarket™](#).

### Visit the Exhibit:

To receive your complimentary badge to the exhibit, complete the [MRS Invitation Reservation Form Here](#) and return to Mary E. Kaufold before April 20, 2011, or bring it to Exhibit Registration located on Level 1 of Moscone West where an exhibit registration badge will be prepared for you.

**Exhibit Hours:**

Tuesday, April 26	11:00 am - 2:00 pm & 4:30 pm - 8:30 pm
Wednesday, April 27	11:00 am - 5:00 pm
Thursday, April 28	10:00 am - 1:30 pm

**Poster Hours:** Thursday, April 28 8:00 pm - 11:00 pm  
[EE9.42, Hollow ZnO Nano Cone Synthesis via Catalyst Free MOCVD](#), Wei Zhang and Karheinz Strobl

**Presentation Hours:** Friday, April 29 11:15 am - 11:30 am  
[Y11.7, First Commercial Applications of Graphene Films Prepared by Chemical Vapor Deposition \(CVD\): High Resolution TEM Grids](#), Elena Polyakova<sup>1</sup>, Daniil Stolyarov<sup>1</sup>, Wei Zhang<sup>2</sup> and Karlheinz Strobl<sup>2</sup>